

# TCAD modeling aided by Machine Learning

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## Research Question

What are the potential methodologies to accelerate TCAD simulation while preserving accuracy?

## Background

- Technology for Computer-Aided Design (TCAD) uses finite element methods (FEMs) to numerically solve for a system of partial differential equations (PDEs).
- Multi-layer perceptron (MLP) uses hidden layers with various activation functions to learn data.
- Photoconductive Semiconductor Switch (PCSS) is an optoelectronic device which leverages a laser input source over leaky metal gate electrodes [1].
- DTCO framework shown below relies on TCAD in early process node development.

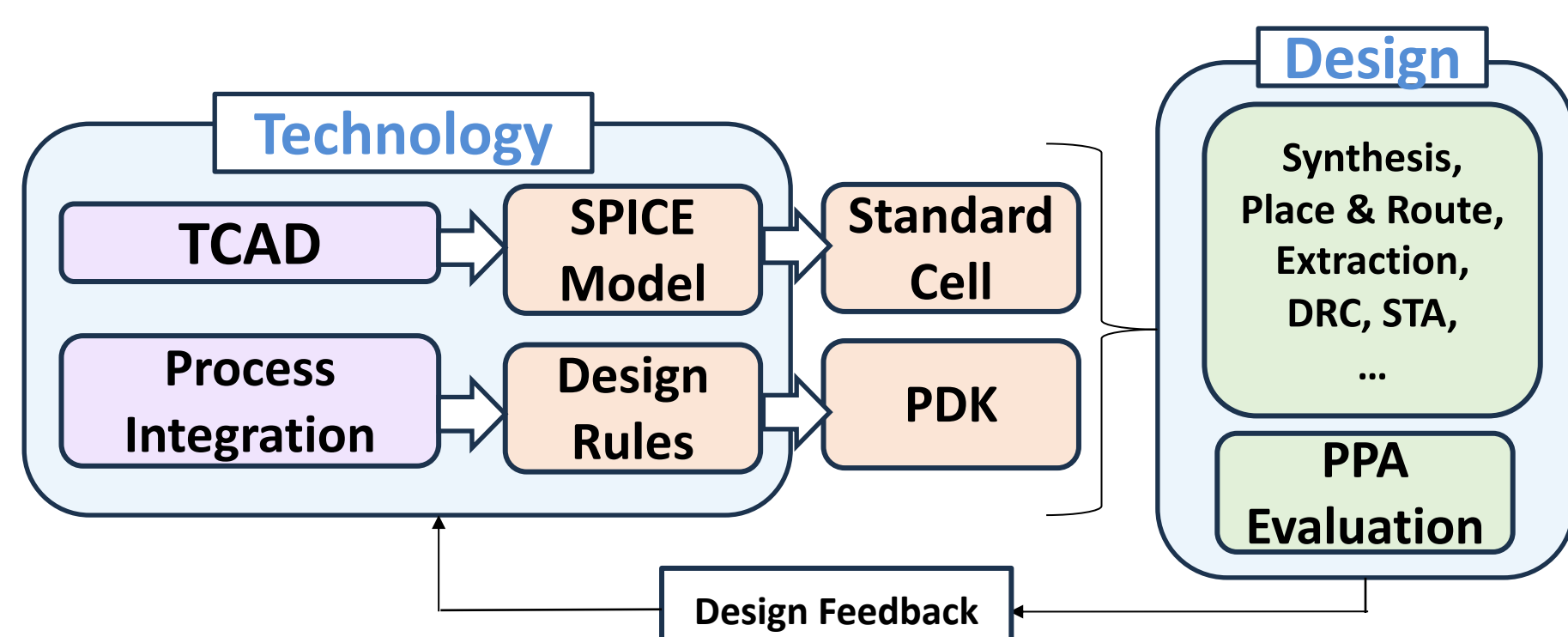


Figure 1: General design-technology co-optimization (DTCO) flow for new devices

## Methodologies

- GaAs PCSS device is solved self-consistently coupling the Poisson's equation with the electron and hole equations.
- Use multi-layer perceptron model with TCAD simulated data to predict output parameters.

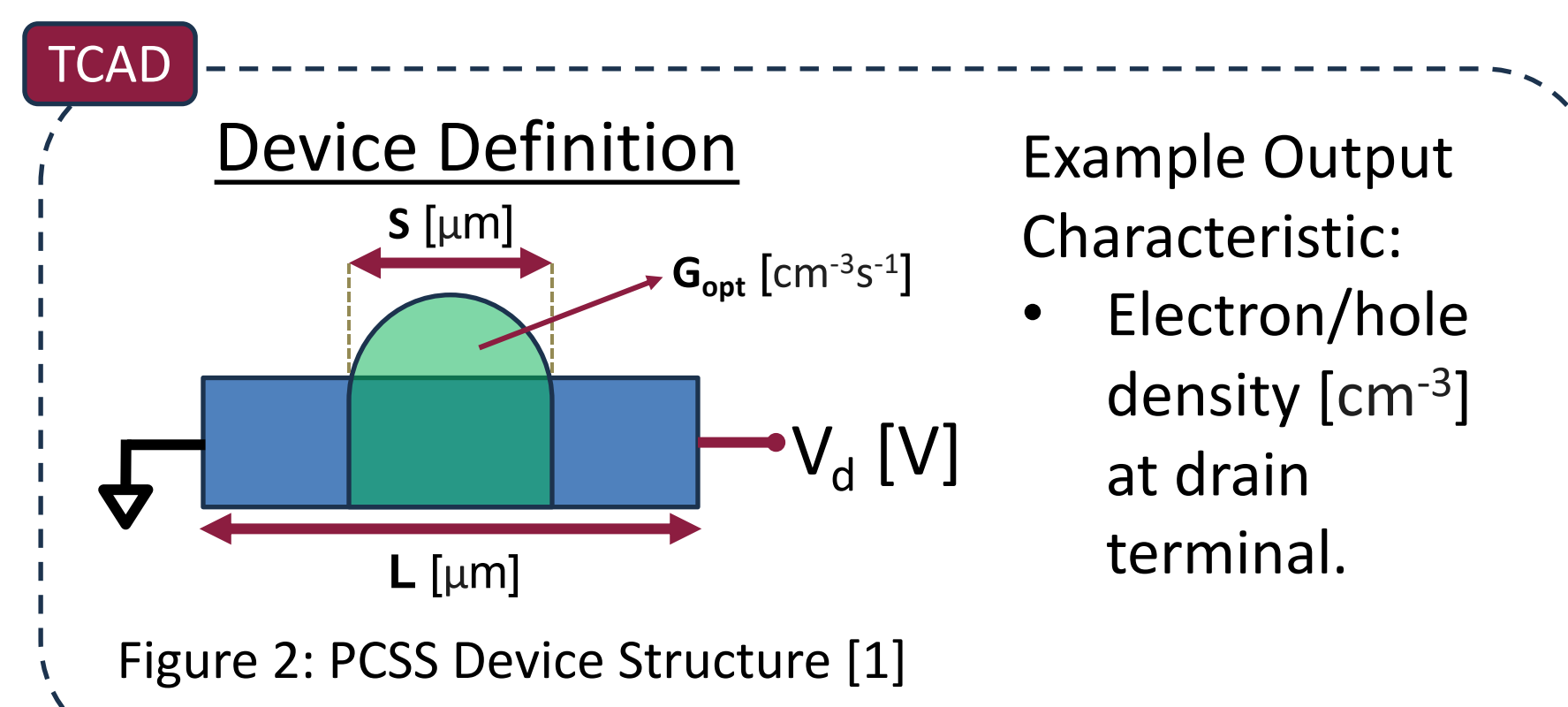


Figure 2: PCSS Device Structure [1]

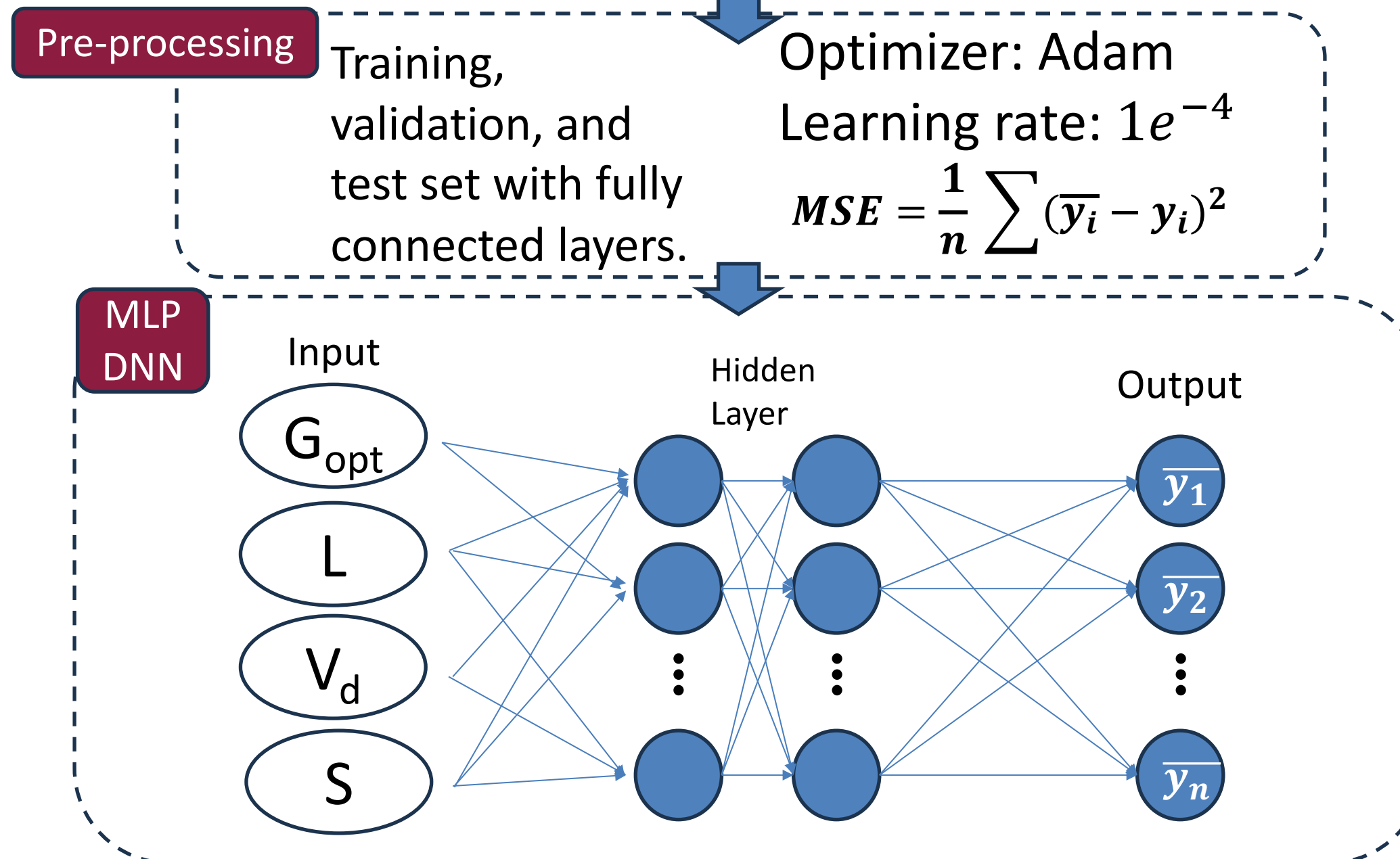


Figure 3: Workflow to train DNN model for TCAD

## Goal

- Use deep learning network as an alternative for rapid convergency in PDE solutions.
- Describe the *output characteristics* of a PCSS device based on *input design parameters* using the trained DLP DNN model.
- Predict device characteristics with minimal error and quick convergence compared to TCAD runtime.
- Provide feedback efficiently for PCSS device optimization (S, Gopt, Vd, L).

## Future Works

- Further train the MLP model with TCAD data using different device structures.
- Use conditional generative adversarial network (cGAN) optimize input parameters for inverse learning and data augmentation.

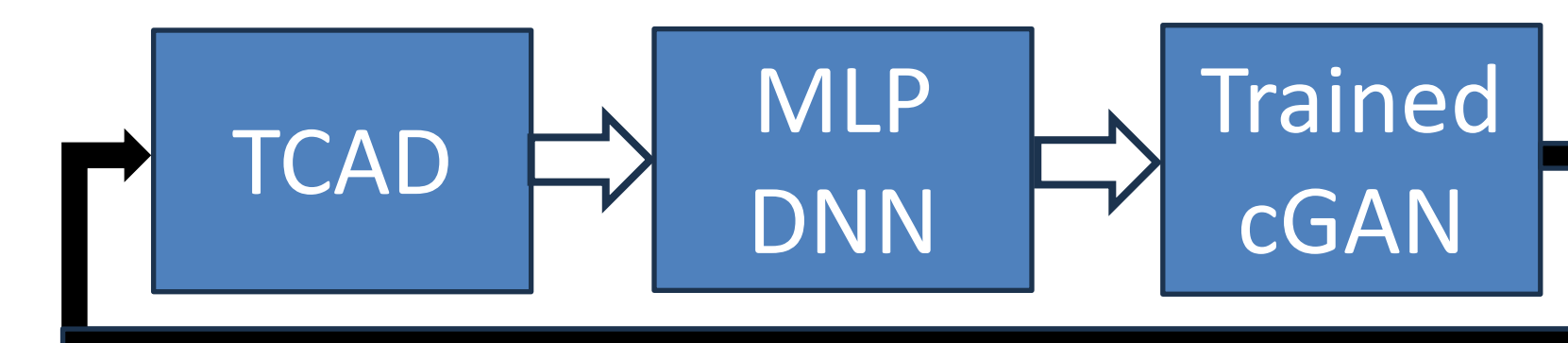


Figure 4: Training cGAN for optimized TCAD inputs and data augmentation.